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Contents

Volume 75 Number 1

AUTHORS		ARTICLES
K.H. Nam, M.J. Jung, J.G. Han, T. Kopte, U. Hartung and C. Peters	1	Synthesis of high-density MgO films by a novel magnetron sputtering system
S. Venkataraj, O. Kappertz, Ch. Liesch, R. Detemple, R. Jayavel and M. Wuttig	7	Thermal stability of sputtered zirconium oxide films
J.Y. Wang, D.K. Sood, M.K. Ghantasala and N. Dytlewski	17	Characterization of sputtered SmCo thin films for light element contamination using RBS and HIERDA techniques
X. Cheng, Z. Lin, Y. Wang, F. Zhang, S. Zou, E. Luo and I.H. Wilson	25	A study of Si epitaxial layer growth on SOI wafers prepared by SIMOX
F. Zhu, X. Bi, S. Zhang, S. Gong and H. Xu	33	Phase transformation and magnetic properties of annealed Fe52.2Co46V1.8 alloy
P. Malar, V. Damodara Das and S. Kasiviswanathan	39	Characterization of stepwise flash-evaporated $CuInSe_2$ films
L. Changshi	51	Plasmons in double interfaces system of $Si_3N_4/SiO_2/Si$ irradiated by ^{60}Co
S. Lee, Y. Moon, J. Yoon and H. Chung	57	Analytical and finite element method design of quartz tuning fork resonators and experimental test of samples manufactured using photolithography 1—significant design parameters affecting static capacitance C_0
C.Z. Liu, L.Q. Shi, S.L. Xu, Z.Y. Zhou, S.Z. Luo and X.G. Long	71	Kinetics of hydrogen uptake for getter materials
H. Jankowski, J. Miller, T. Pisarkiewicz, M. Warzecha and C. Worek	79	A model for a device with radiation heat transfer for selenization of Cu/In metallic precursors in photovoltaic applications
S.B. Wang, S.B. Zhou and X.J. Yi	85	Preparation of homogeneous VO_X thin films by ion beam sputtering and annealing process
F. Gołek	91	Miniature Auger spectrometer with grazing incidence electron beam

Volume 75 Number 2

X.W. Wen, X.L. Jiang, L.J. Han and Y.P. Tan	99	Fabrication of ferroelectrics $LiNbO_3$ thin films by pseudospark electron beams
S. Seelan, D.W. Hwang, L.-P. Hwang and A.K. Sinha	105	Synthesis of multiwalled carbon nanotubes by high-temperature vacuum annealing of amorphous carbon

doi:10.1016/S0042-207X(04)00284-2

S. Gupta, R.K. Roy, M.P. Chowdhury and A.K. Pal	111	Synthesis of SnO_2/Pd composite films by PVD route for a liquid petroleum gas sensor
D.Q. Peng, X.D. Bai, Q.G. Zhou, X.W. Chen, X.Y. Liu, R.H. Yu and P.Y. Deng	121	The oxidation behaviour of molybdenum ion-implanted zircalloy-4 in air at 600°C
A.M. Efremov, D.-P. Kim and C.-I. Kim	133	Effect of gas mixing ratio on gas-phase composition and etch rate in an inductively coupled CF_4/Ar plasma
T.D. Radjabov, A.I. Kamardin and A.V. Sharudo	143	The investigation of two-layer protective-decorative coatings on oxide substrates
F.F. Komarov, L.A. Vlasukova, P.I. Gaiduk, A.M. Mironov, W. Wesch, A.A. Kamarou and V.N. Yuvchenko	149	Redistribution of indium implanted in silicon due to thermal treatment and swift heavy ion irradiation
V.V. Anashin, I.R. Collins, R.V. Dostovalov, N.V. Fedorov, A.A. Krasnov, O.B. Malyshev and V.L. Ruzinov	155	Comparative study of photodesorption from TiZrV coated and uncoated stainless steel vacuum chambers
X.W. Xi, Y.J. Chen and X.Y. Zhang	161	Growth and magnetic properties of soft ferrite films by pulsed laser deposition
W. Jitschin and S. Ludwig	169	Dynamical behaviour of the Pirani sensor
B. Kobbi and N. Kesri	177	Physico-chemical and electrical properties of InSe films
Y. Hu, X. Diao, C. Wang, W. Hao and T. Wang	183	Effects of heat treatment on properties of ITO films prepared by rf magnetron sputtering

Volume 75 Number 3

A.A. Ibrahim, N.Z. El-Sayed, M.A. Kaid and A. Ashour	189	Structural and electrical properties of evaporated ZnTe thin films
A. Choukourov, J. Kousal, D. Slavínská, H. Biederman, E.R. Fuoco, S. Tepavcevic, J. Saucedo and L. Hanley	195	Growth of primary and secondary amine films from polyatomic ion deposition
V. Stelmashuk, H. Biederman, D. Slavínská, M. Trchová and P. Hlidek	207	Rf magnetron sputtering of polypropylene
X. Chen, H. Qiu, H. Qian, P. Wu, F. Wang, L. Pan and Y. Tian	217	Characteristics of Ni_xFe_{100-x} films deposited on SiO_2/Si(100) by DC magnetron co-sputtering
Q. Wang, H. Ishikawa, S. Nakano, H. Ogiso and J. Akedo	225	Curvature-based residual stress measurement for ion-implanted stainless-steel sheet
X. Yu, X. Zhang, C.-b. Wang, M. Hua and L. Wang	231	A tribological study of tetrahedral amorphous carbon films prepared by filtered cathodic vacuum arc technique
A.M. Efremov, D.-P. Kim and C.-I. Kim	237	Inductively coupled Cl_2/O_2 plasma: experimental investigation and modelling
S. Taktak and H. Akbulut	247	Diffusion kinetics of explosively treated and plasma nitrided Ti–6Al–4V alloy
A. Grigonis, V. Sablinskas, M. Silinskas and D. Tribandis	261	The role of hydrogen in a-C:H films deposited from hexane or acetylene using direct ion beam deposition method
A. Meftah, A. Meftah and A. Merazga	269	Created defect under illumination in a-Si:H: hydrogenated or isolated dangling bond?

H.-C. Lee and O.O. Park	275	Electron scattering mechanisms in indium-tin-oxide thin films: grain boundary and ionized impurity scattering
K.B. Thakur and G.K. Sahu	283	Spatial distribution function for vapour flow and its validation for a two-dimensional source generated using strip electron beam

Volume 75 Number 4

V.V. Anashin, I.R. Collins, R.V. Dostovalov, Z.A. Korotaeva, A.A. Krasnov, O.B. Malyshev and V.A. Poluboyarov	293	Vacuum performance of a carbon fibre cryosorber for the LHC LSS beam screen
S. Alexandrova, A. Szekeres, E. Halova, I. Lisovskyy, V. Litovchenko and D. Mazunov	301	Oxide and interface charges in thin SiO_2 films thermally grown on RF plasma hydrogenated silicon
F. Hamelmann, A. Aschentrup, A. Brechling, U. Heinzmann, A. Gushterov, A. Szekeres and S. Simeonov	307	Plasma-assisted deposition of thin silicon oxide films in a remote PECVD reactor and characterization of films produced under different conditions
S.P. Singh, S. Kumar and A. Kumar	313	Effect of some metallic impurities on the density of localized states in a-$Se_{80}Te_{20}$ thin films
A.M. Efremov, D.P. Kim, K.T. Kim and C.I. Kim	321	Etching characteristics and mechanism of $Pb(Zr,Ti)O_3$ thin films in CF_4/Ar inductively coupled plasma
I.C. Oliveira, K.G. Grigorov, H.S. Maciel, M. Massi and C. Otani	331	High textured AlN thin films grown by RF magnetron sputtering; composition, structure, morphology and hardness
U. Sen	339	Kinetics of titanium nitride coatings deposited by thermo-reactive deposition technique
K. Tamura	347	Measurements of energy spread and intensity distributions of the laser photo-ionized neodymium ions
H.-d. Wang, B.-s. Xu, J.-j. Liu and D.-m. Zhuang	353	Tribological properties and mechanisms of sulfide layer prepared by glow discharge
A. Amoli and S.M. Hosseinalipour	361	A continuum model for pumping performance of turbomolecular pumps in all flow regimes
M. Chegaar, Z. Ouennoughi and F. Guechi	367	Extracting dc parameters of solar cells under illumination
Q.-Y. Wen, H.-W. Zhang, X.-D. Jiang, X.-L. Tang and W.-L. Zhang	373	Magnetoresistance and microstructure evolution upon rapid thermal annealing of giant magnetoresistive Co/Cu/Co/CoNbZr multilayers
	VII	VOLUME CONTENTS
	XI	AUTHOR INDEX